

Amorphous Coatings

Current Status — Future Plans

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Coating Thermal Noise

- ✦ Limits the sensitivity for 2nd Generation detectors
- ✦ Reduced by changing (in current interferometer design)
 - ✦ Form factor: Laguerre-Gauss beams
 - ✦ Dissipation in the coating
 - ✦ Redesign the coating structure:
 - ✦ Etched Refractive layers: *Jena (S. Kroker talk)*
 - ✦ Crystalline coatings: *Vienna (G. Cole talk)*
 - ✦ **Reduce the loss in Amorphous Coatings**

Amorphous (Metal-Oxide) Coatings

✦ Optical Quality

- ✦ Can provide ppm level scattering and absorption
- ✦ Significant History and Industry for these coatings

✦ Mechanical Quality

- ✦ Dissipation predominantly in material
 - ✦ Loss at interface still being explored
- ✦ Material Structure Research: *Determine loss mechanism / Redesign Coating*
 - ✦ Theoretical work: *UFlorida & Southern U.*
 - ✦ Experimental work:
 - ✦ Reduced Density Function to model structure: *Stanford (R. Bassiri talk)*
 - ✦ Activation Energy of loss mechanisms: *Glasgow (I. Martin talk)*
- ✦ Optimize Coating Structure: *USannio (R. DeSalvo talk)*
- ✦ **Optimize Coating Materials: *Material Selection and Processing***

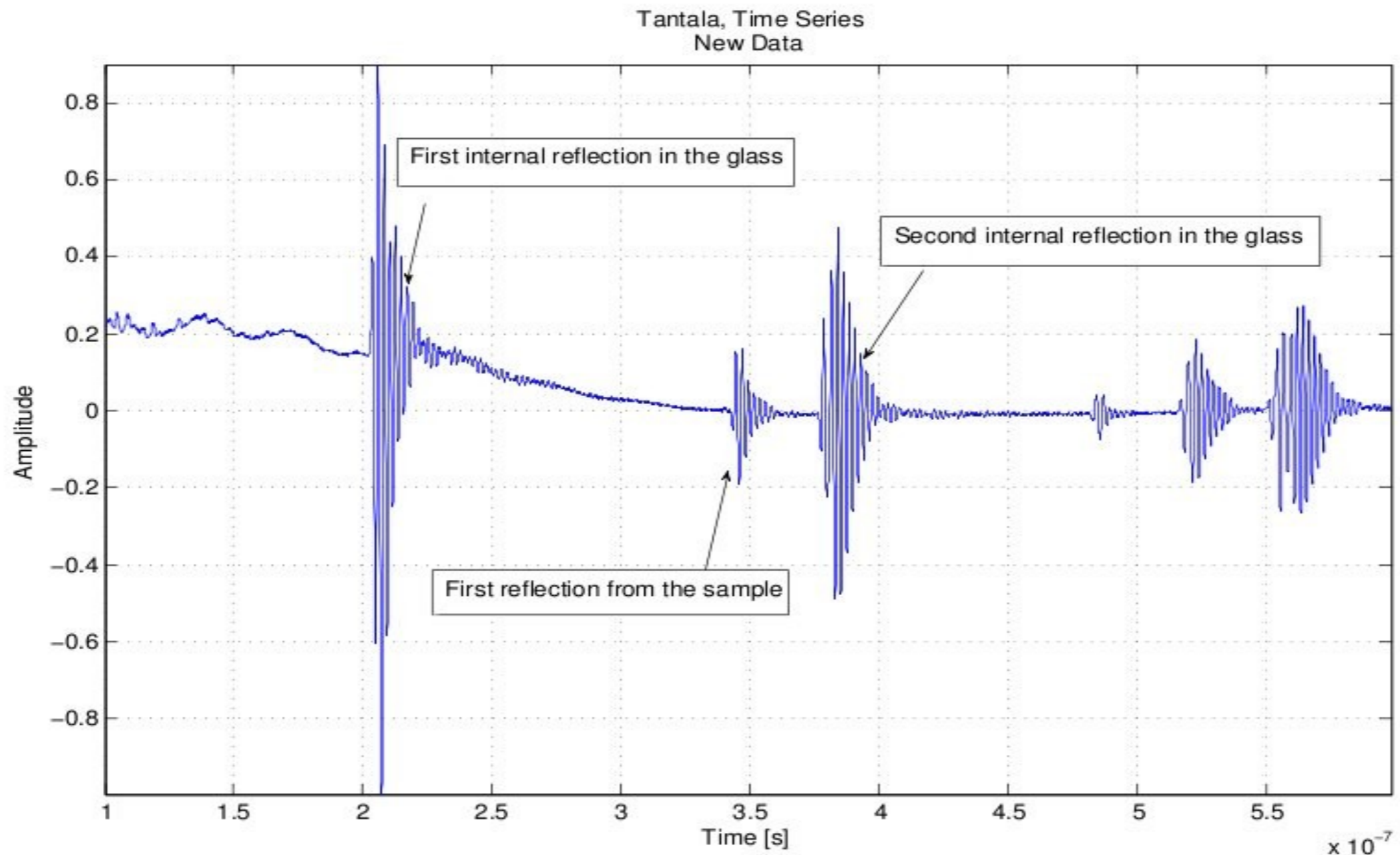
Optimize Amorphous Coatings: Material Properties

- ◆ **Material Properties:** *Ion Beam Sputtering (IBS) process alters properties*
 - ◆ Residual stress (compressive)
 - ◆ Variable thermal annealing history (reduce stress & absorption)
- ◆ **Young's Modulus:**
 - ◆ NanoIndenter: *Glasgow (M. Abernathy)*
 - ◆ Ultrasonic reflection: *Embry-Riddle (M. Zanolin, A. Gretarsson)*
- ◆ **Coating Phi Components**
 - ◆ Torsional loss in coatings - Test ϕ_{\perp} vs ϕ_{\parallel} : *American (G. Harry)*

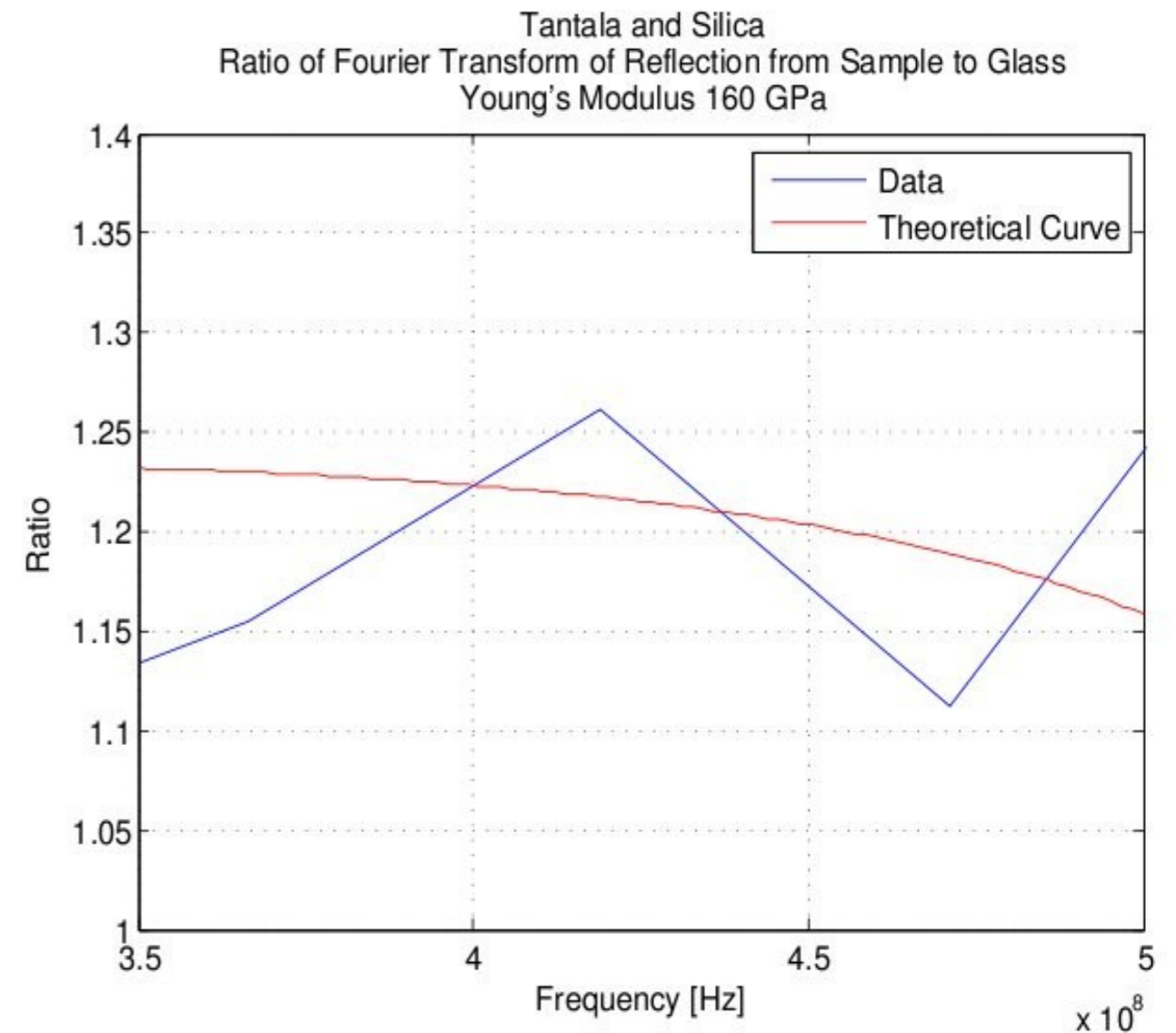
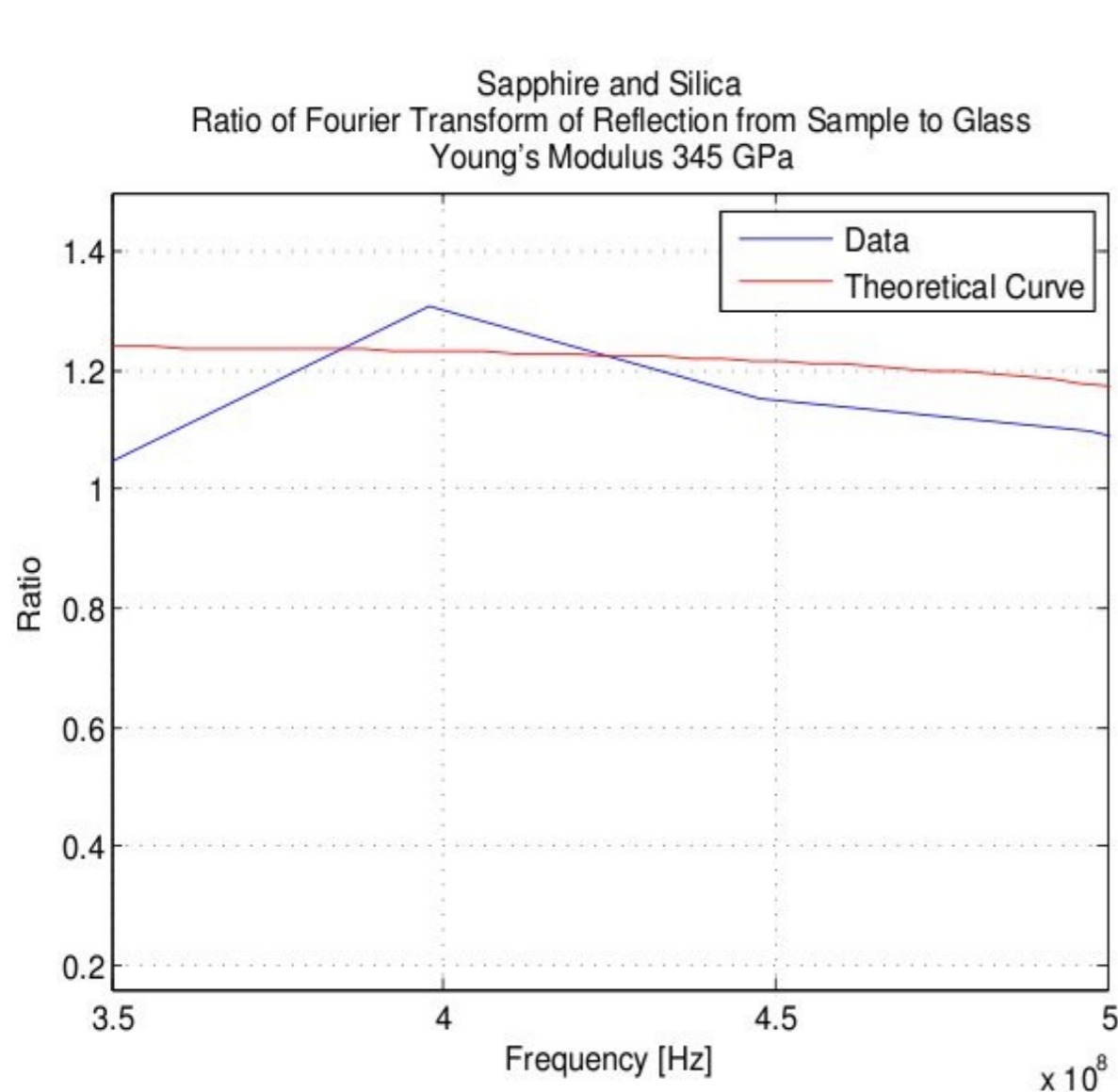
$$S_x(f)_{\text{coating}} = \frac{2k_B T}{\pi^2 f Y} \frac{d}{w_m^2} \left(\frac{Y'}{Y} \phi_{\parallel} + \frac{Y}{Y'} \phi_{\perp} \right)$$

Ultrasonic measurement of Young's modulus of LIGO coatings at ERAU

A.Gretarsson, E.Gretarsson, E.Rhoades, M.Zanolin



Two examples



- The two plots show the ratio of the reflection coefficient of a sapphire substrate (left) and a 5 microns Tantala coating on a silica substrate (right) with respect to the reflection coefficient of a silica substrate. The blue curve is the average spectrum of 5 measurements and the red is a theoretical one where the free parameter is the YM of the testing sample (pure sapphire and Tantala coating). The quoted estimate above the pictures is a least square estimate.

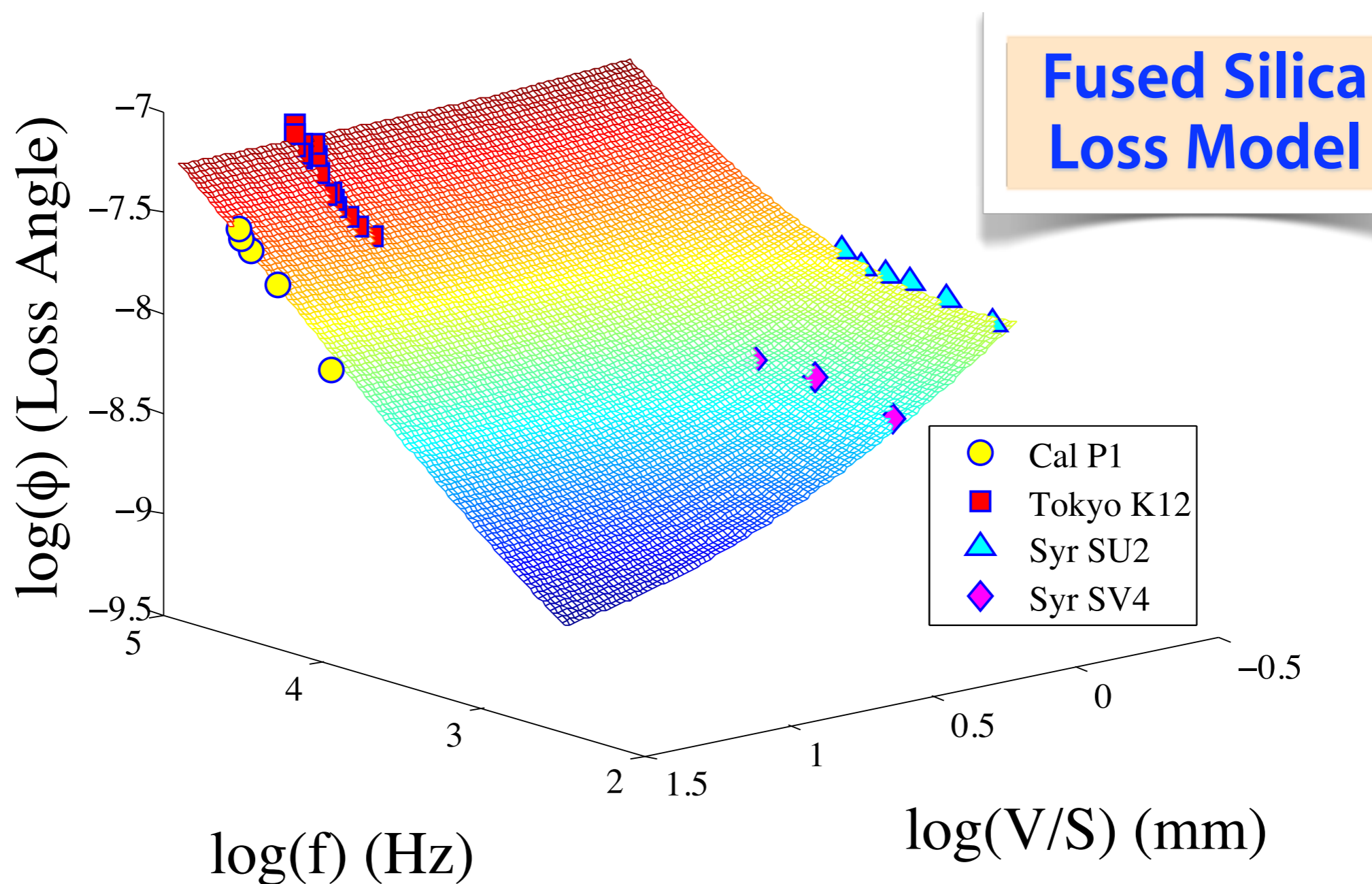
Optimize Amorphous Coatings: Material Selection

- ◆ High Index: *Tantala, Titania, ... Zirconia, Niobia, Hafnia*
 - ◆ Loss as coated are comparable: $\text{few} \times 10^{-4}$
 - ◆ **Tantala:** Moderately stable (300–400° C), $n \approx 2.1$
 - ◆ **Titania:** Less stable (200° C). $n \approx 2.5$
 - ◆ **Zirconia:** High Absorption, 10-50 ppm
 - ◆ **Niobia:** High loss 4.5×10^{-4}
- ◆ Doped High-Index Materials:
 - ◆ **Titania(20%)-Tantala:**
 - ◆ Lowers loss to 2×10^{-4} , Stabilizes Titania, index admixture
 - ◆ Measurements to 55%-doping under analysis. Proposed 90% run.
 - ◆ **Silica-doped (Titania/Tantala/...)**
 - ◆ Stabilizes high-index material
 - ◆ Lowers index — mixture determines index
 - ◆ Little gain in loss

Optimize Amorphous Coatings: Silica

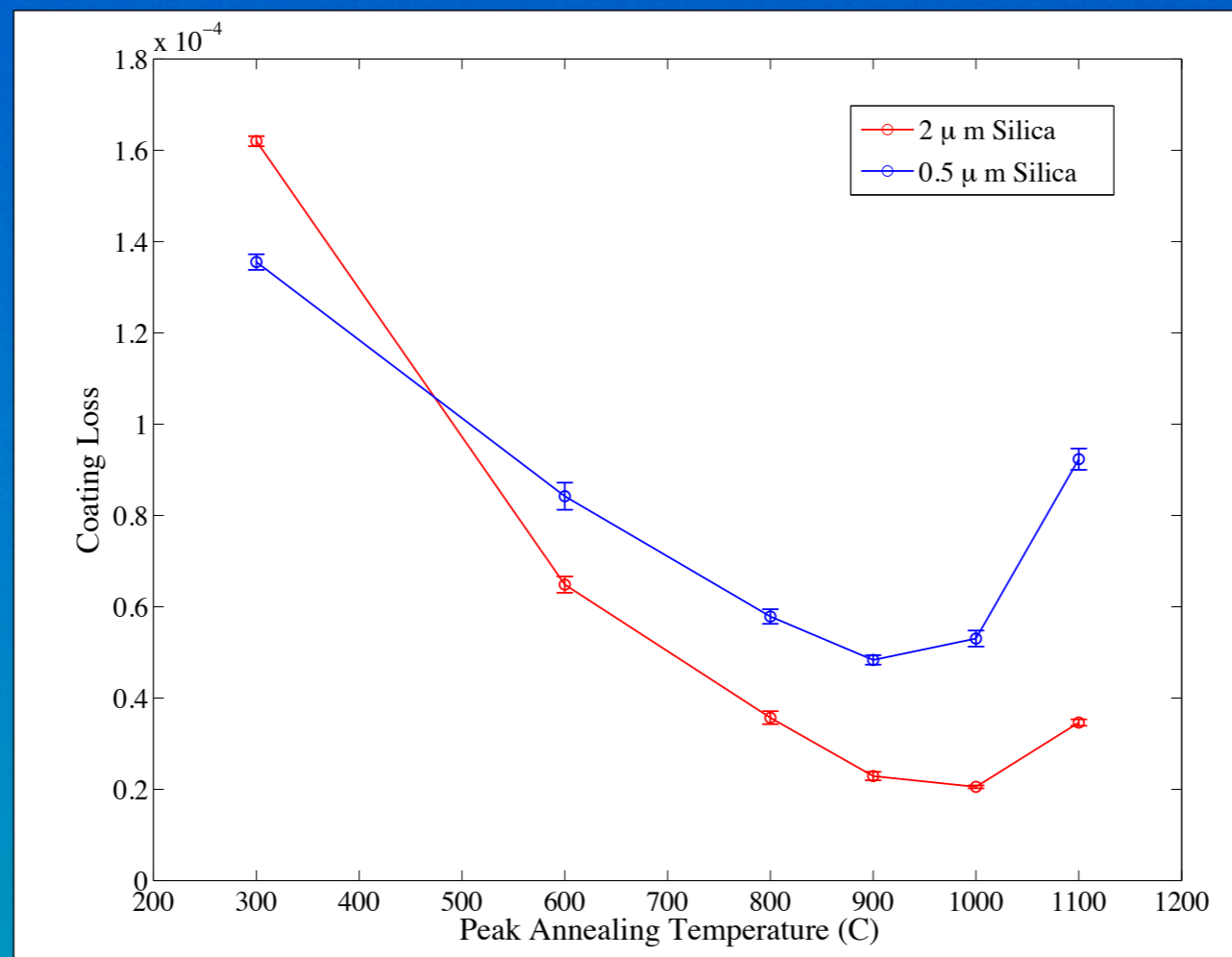
- ♦ **Silica:** Loss Model. Lowest loss $\phi \approx 5 \times 10^{-9}$
- ♦ Coating loss is well measured as bulk and as a coating.

$$\phi = (6.52e-09 \text{ S/V } f^0 + 7.64e-12 f^{0.77} + 1 \phi_{\text{th}})$$



Optimize Amorphous Coatings: Annealing

- ◆ Annealing: *Provided that the sample remain amorphous*
 - ◆ Reduces mechanical loss by a factor of few to several depending on the material. (8x for 2 micron silica)
 - ◆ Reduces optical absorption by equally larger factor (zirconia reduced from 100 ppm to 10 ppm by 900° C)



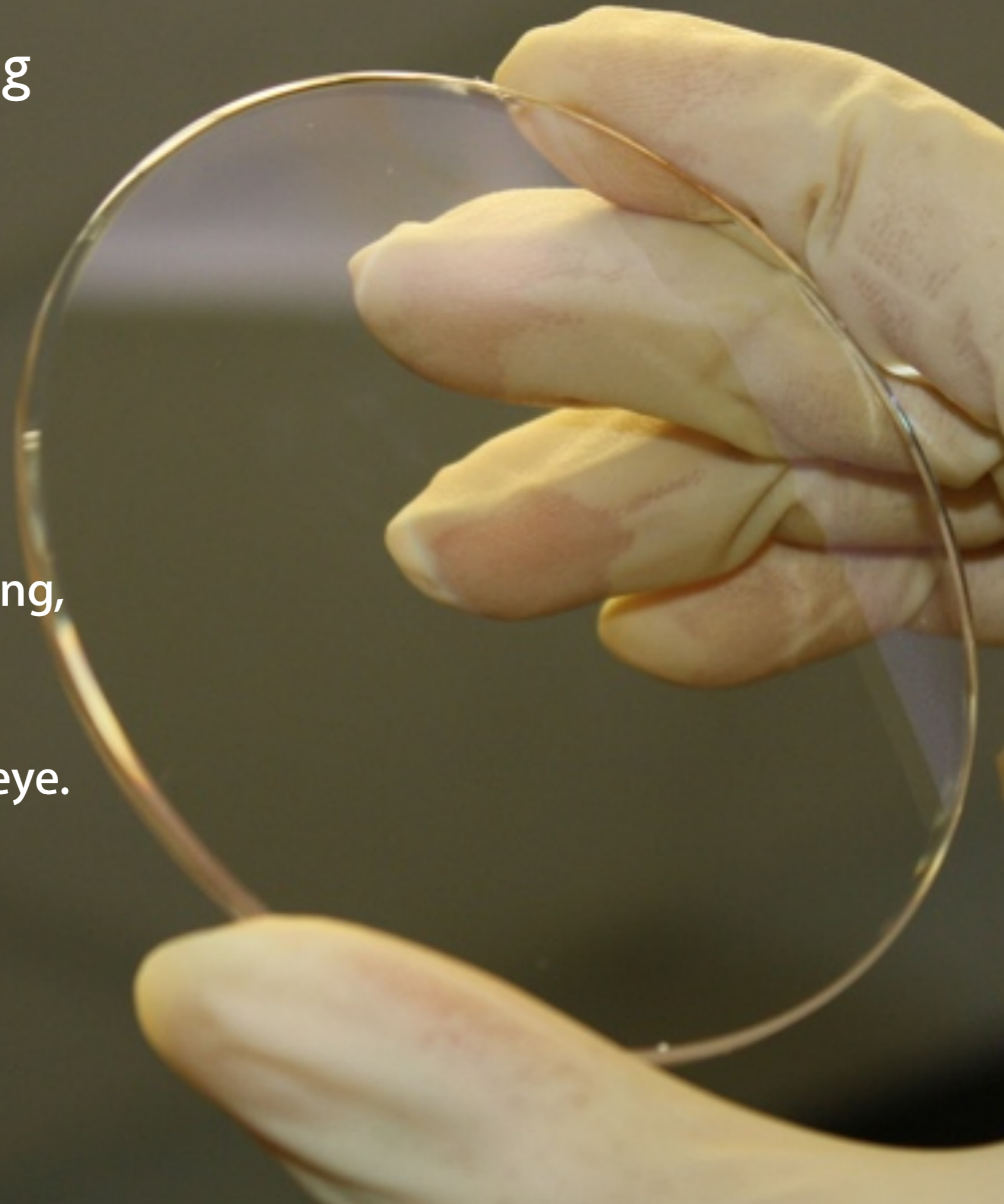
Optimized Coatings via Annealing

- 1) Select, or mix, a high-index coating material
 - 1) Match the CTE to silica (or low-index material)
 - 2) Dope against crystallization
- 2) Make a quarter-wavelength multilayer
- 3) Anneal to 1000° C

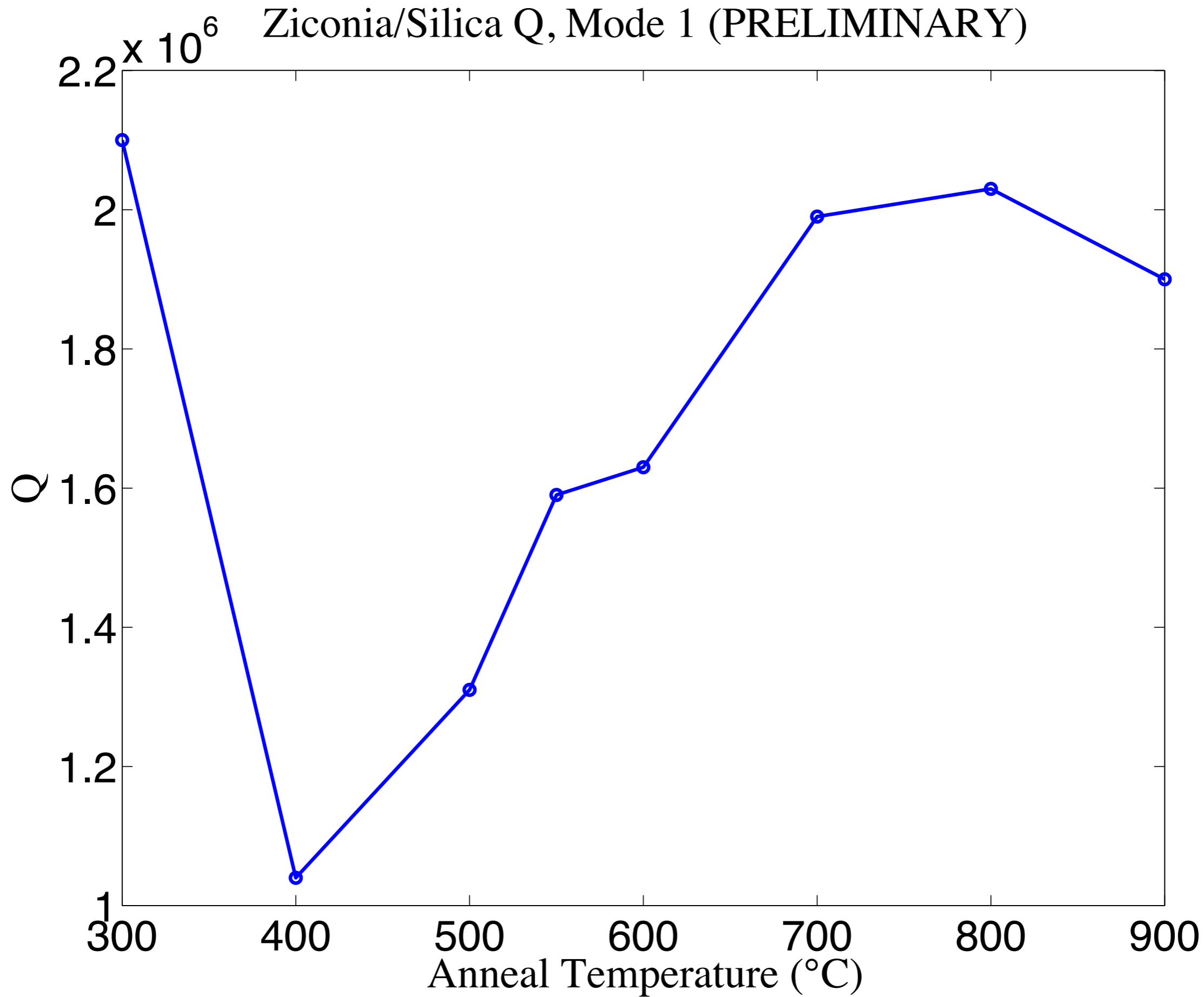
Zirconia/Silica Coating

(2 $\lambda/4$ doublets)

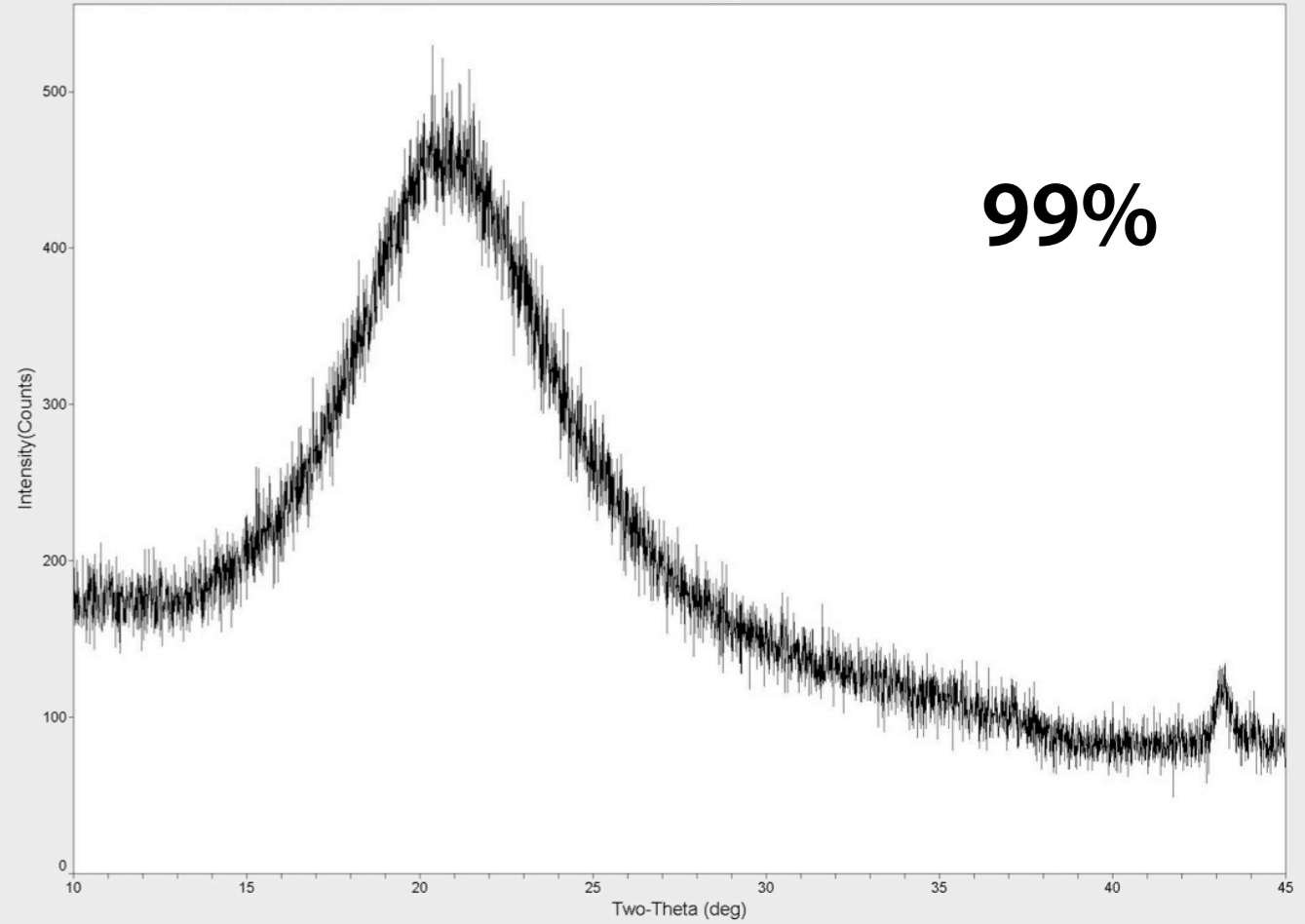
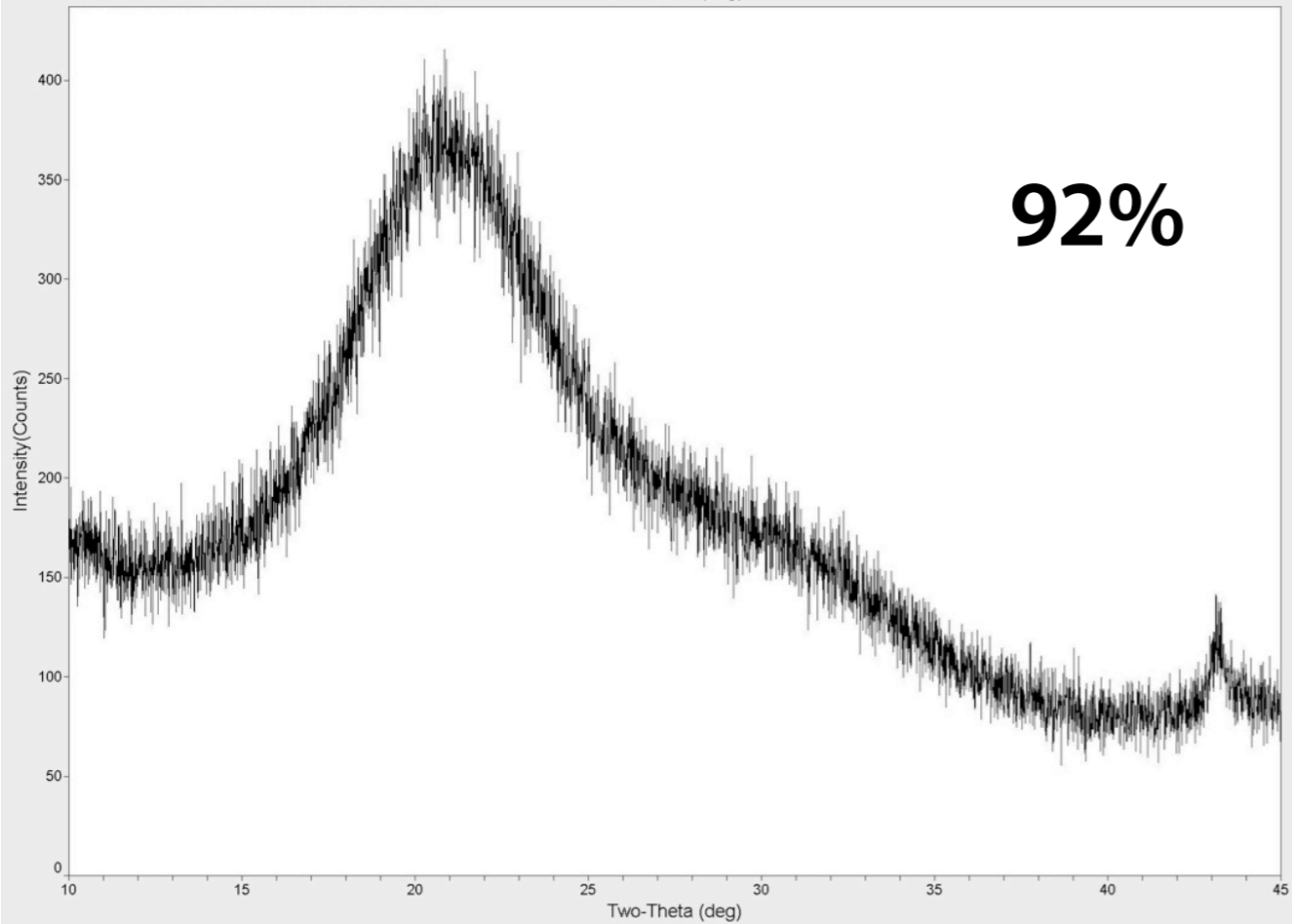
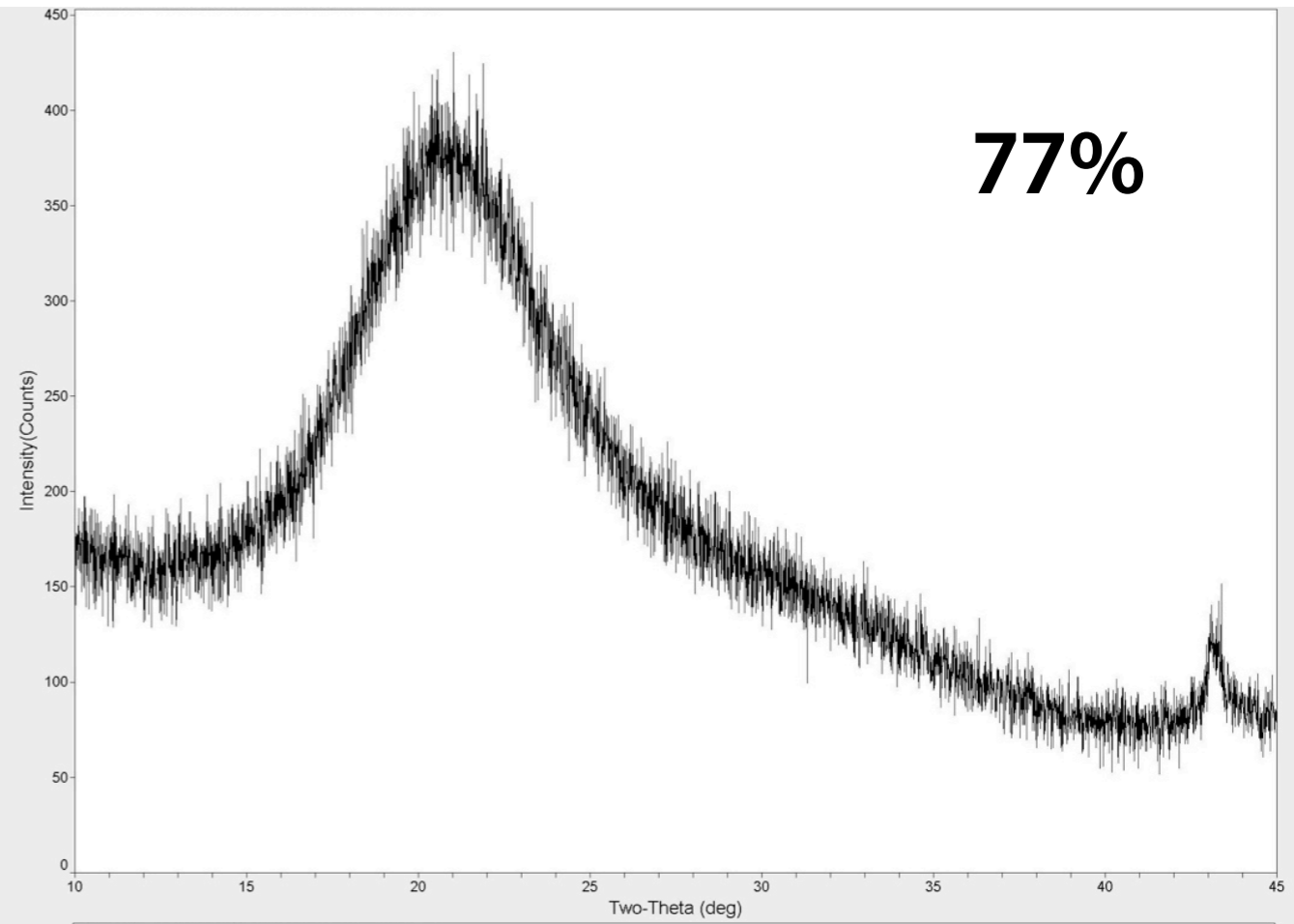
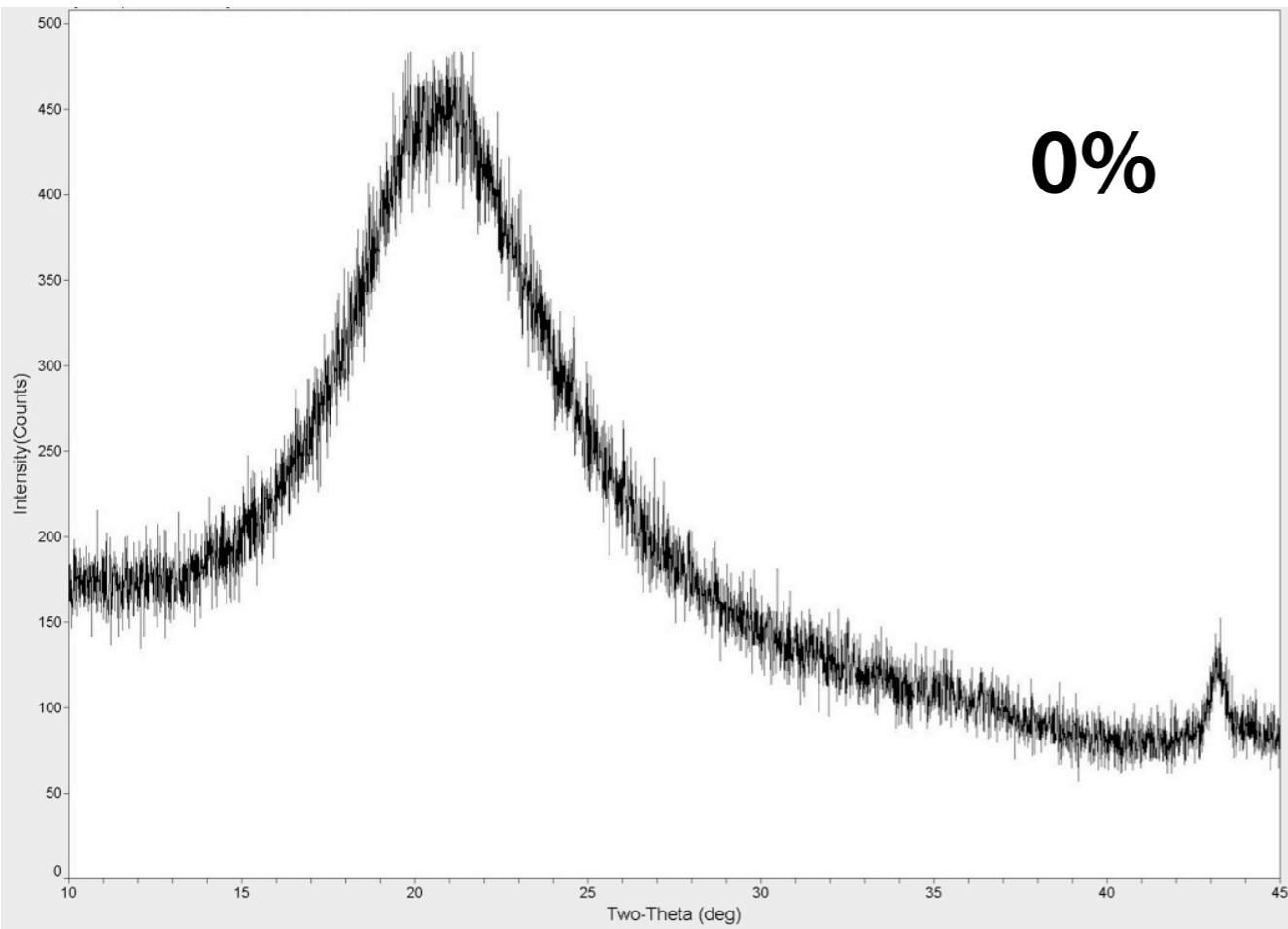
- ✦ Annealed up to 1000°C
- ✦ No peeling, bubbles, crazing, or loss of adhesion.
- ✦ At 1000° C, excess scatter detectable with naked eye.
- ✦ X-ray diffraction shows crystallization
- ✦ Scatter only 10x than superpolished sample
- ✦ Absorption $\approx < 10$ ppm



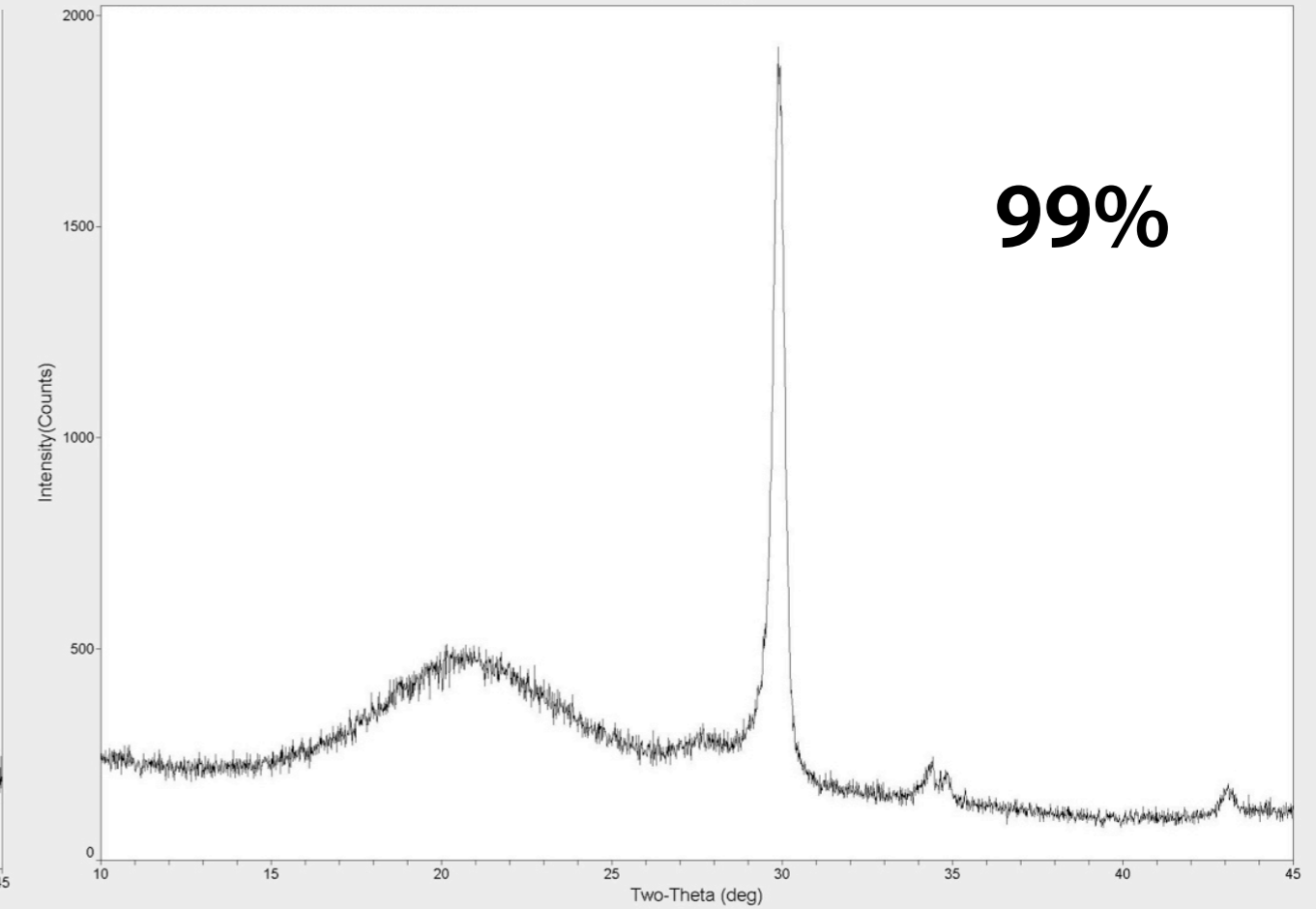
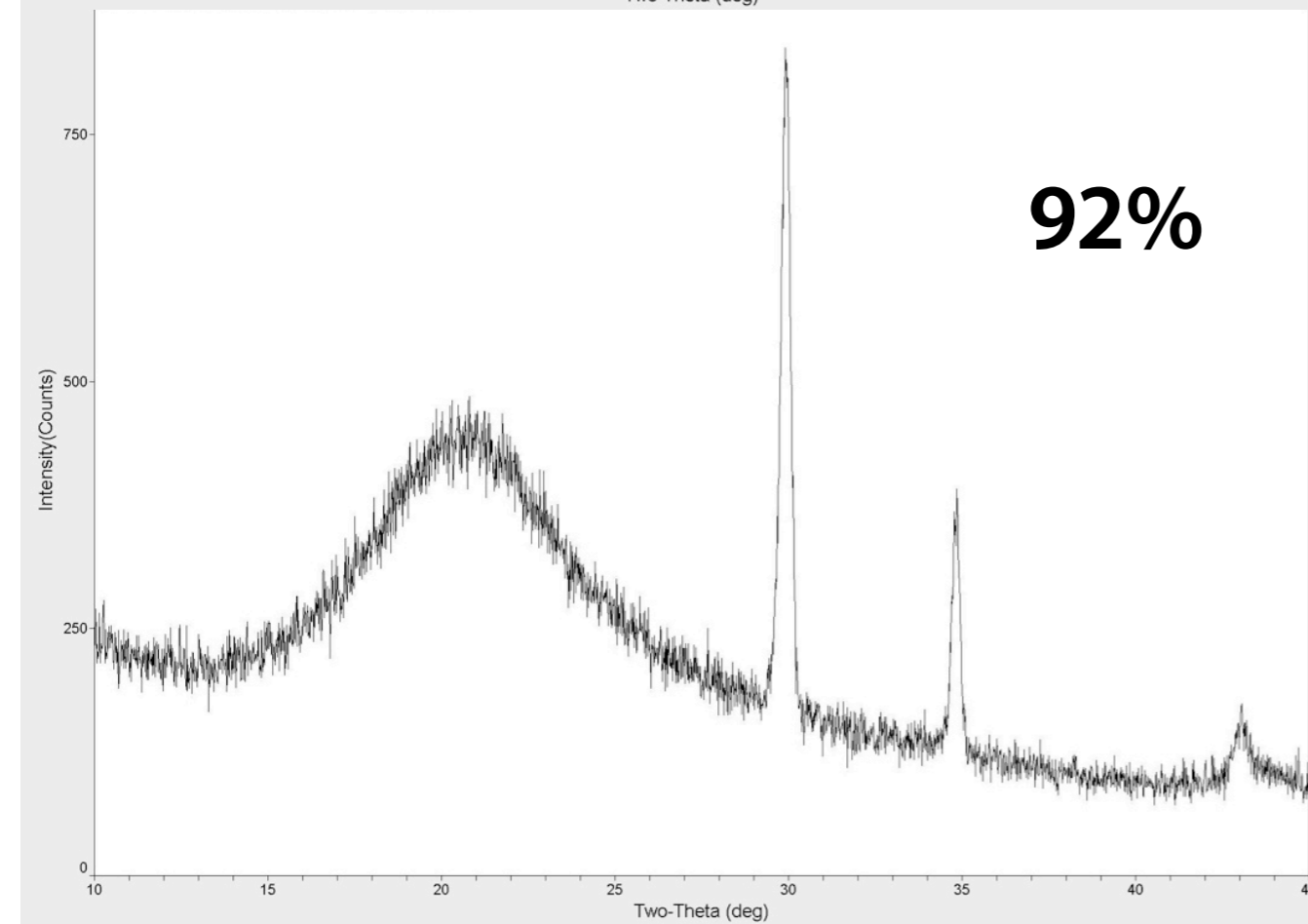
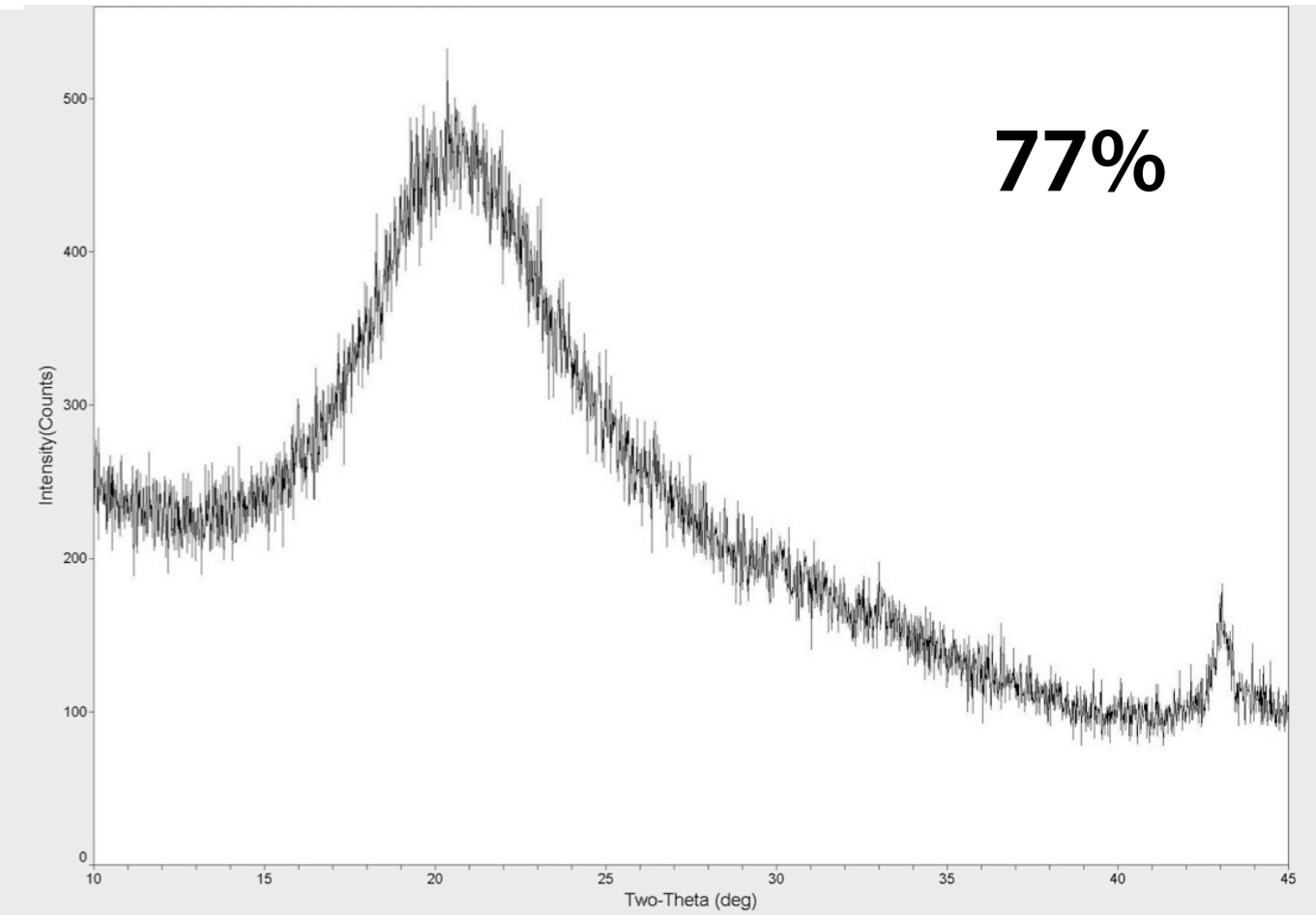
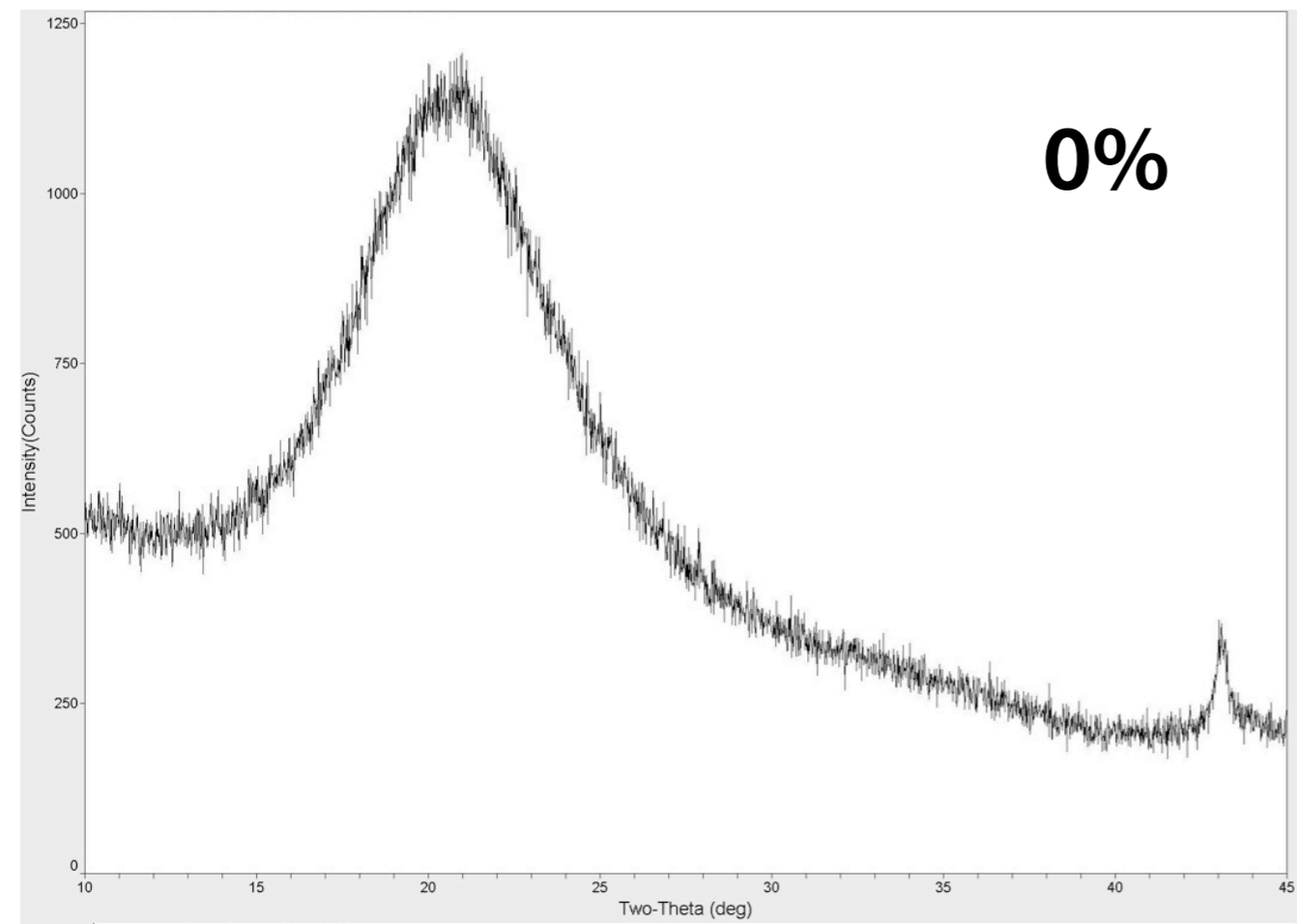
Ziconia/Silica Q, Mode 1 (PRELIMINARY)



X-ray Diffraction of Silica-doped Zirconia, Anneal $\approx 300^\circ\text{C}$



X-ray Diffraction of Silica-doped Zirconia, Anneal $\approx 600^\circ\text{C}$



Summary

- IBS produced Amorphous coatings can provide the required optical qualities for Advanced Generation of detectors.
- Current coating loss “acceptable”, but should be improved
- Considerable effort being devoted to characterize and understand the physical characteristics, structure, and loss mechanisms of amorphous coatings.
- Doping has provided the most significant improvement ($\approx 40\%$) in a complete multilayer coating (Ti-doped-Tantala/Silica)
- Annealing has shown improvements of few-several in the loss.
- Silica-doped Zirconia is a test of principle.